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U.S.S.N. 10/769,245

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

re: Application of:
Hsin-Hsien Lu Group Art Unit: 1751
Serial No.: 10/769,245 Examiner: Lorna M. Douyon
Filed: Jan. 30, 2004 In Response to Office Action
Dated: May 10, 2005
For: Noel Method for Polishing Pad and Wafer Cleaning
Attorney Docket No.: 67,200-1192

Certificate of Mailing

I hereby certify that this paper is being deposited with the United States Postal Service on the date shown below with sufficient postage as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Kathy Dixon
Name of person mailing paper

Mailing Date: June 9, 2005

RESPONSE TO OFFICE ACTION

Commissioner for Patents
Alexandria, VA 22313-1450

Dear Sir:

In response to an Office Action mailed May 10, 2005 of a restriction requirement imposed by the Examiner, the Applicants hereby elect with traverse the prosecution of Group I, method claims 1-16.